

附件 1 不同电流下聚焦位置和 VPL 核团处电场强度

a-h. 300~1 000 μ A 时 TI 神经调控方法聚焦位置和电场强度

Supplement 1 Electric field intensity at the focusing position and VPL nuclei at different currents

a-h. focus situation and electric field intensity of TI neuromodulation method at 300-1 000 μ A



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附件 2 小鼠左转视频

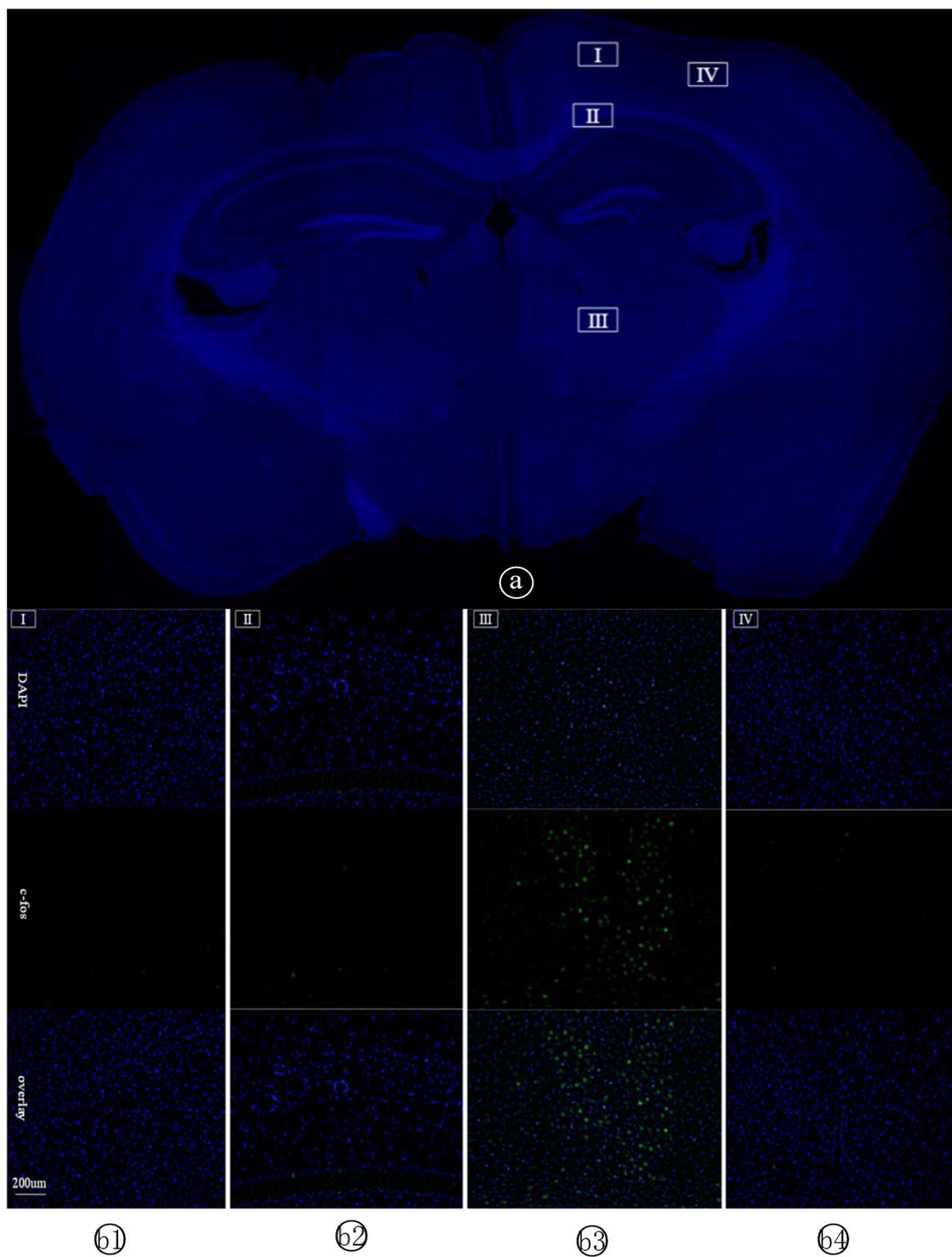
Supplement 2 Video of mouse left turn



右转.mp4

附件 3 小鼠右转视频

Supplement 3 Video of mouse right turn



附件 4 多区域 c-Fos 阳性细胞对比

a. 荧光显微镜下采集的小鼠脑切片整体图；b1~4. I~IV区域采集的 DAPI 图像、c-fos 阳性细胞图像以及 DAPI、c-fos 重叠图像

Supplement 4 Comparison of c-Fos-positive cells in multiple regions

a. overall view of a mouse brain section collected under fluorescence microscope; b1-4. DAPI images, c-fos-positive cell images, and DAPI and c-fos overlap images acquired in region I~IV